SPIE. ADVANCED LITHOGRAPHY+ PATTERNING

Sponsor Student Grants

Increase student participation at Advanced Lithography + Patterning 25–29 February 2024

The Sponsored Student Grant has been developed to encourage student participation and research contributions in the field of advanced lithography. While funds last, financial support will be extended to select students wishing to attend the Advanced Lithography + Patterning Symposium and one related course. Students must complete an application for the grant, and recipients will be selected by a committee composed of conference chairs and committee members. Priority will be given to student authors, but all students are encouraged to apply.

Sponsorship details:
- Sponsors receive logo placements in the event program, website, room slides, and onsite banner, plus access to student contact information.
- Cost per sponsor: $5,000
- Deadline: 1 November 2023
- Sponsors are encouraged to attend the student events to meet the students they've supported.

How funds will be distributed:
Funds are sent to SPIE by sponsors and held in a student grant account specifically for SPIE Advanced Lithography + Patterning 2024. Registration fees will be covered for all accepted students, and each student will receive travel and lodging reimbursement, as well as registration costs for one course until funds are depleted, with priority given first to primary authors and then to non-authors.

Any excess funds will be transferred to future years' student grants.

Requirements for grant awardees:
- Applicants must be students.
- Applications must be completed by the deadline.
- If the student is an author, they must submit a manuscript by the specified date.

Email Josephine Hegeberg (josephineh@spie.org) for more information or to confirm involvement.